



PMB110T060SS-255A

15A/60V⁽¹⁾, low VF Planar MOS barrier diode

Mechanical Data

| Chip Drawing | Item | Information | |
|--------------|---------------------------------|---|-----------|
| | Die Size (A) | 2794μm | 110.0 mil |
| | Top Metal Pad Size (B) | 2674μm | 105.3mil |
| | Chip Size (C) | / | / |
| | Wafer Thickness (D) | 255 μm | 10.0 mil |
| | Scribe Line Width (E) | 80 μm | 3.15 mil |
| | Wafer Size | 6 inch | |
| | Top Side Metallization | PMB110T060SS-255A | Ag |
| | Back Side Metallization | Ti Ni Ag | |
| | Recommended Storage Environment | Stored in original container, in dry nitrogen, (6 months at an ambient temperature of 23°C±3°C) | |

Electrical Characteristics (T_J=25°C, unless otherwise specified) ⁽²⁾

| Parameter | Description | Min. | Typ. | Max. | Unit | Test Condition |
|-----------------------------------|-----------------------------------|--------------------|------|------|------|------------------------------------|
| V _{BR} | Reverse Breakdown Voltage | 62 | 67 | - | V | I _R =300μA |
| V _F | Instantaneous Forward Voltage | - | 0.48 | 0.55 | V | I _F =15A ⁽³⁾ |
| I _R | Reverse Leakage Current | - | 90 | 150 | μA | V _R =60V |
| T _J , T _{STG} | Operating and Storage Temperature | -40°C to 150°C Max | | | | |

Note:

(1) The preliminary wafer datasheet only for reference;

(2) This characteristics assumes the dies are assembled in TO-277 packages. Actual performance may degrade when assembled.

YJ does not guarantee device performance after assembly;

(3) Pulse Width t_p = < 300μS, Duty Cycle <2%;